

L Number	Hits	Search Text	DB	Time stamp
1	324148	spacer\$1 or sidewall\$1	USPAT; US-PGPUB; JPO	2002/06/18 15:47
2	63193	anisotropic\$4 or rie	USPAT; US-PGPUB; JPO	2002/06/18 15:47
3	483214	gate\$1	USPAT; US-PGPUB; JPO	2002/06/18 15:48
5	109124	implant\$3	USPAT; US-PGPUB; JPO	2002/06/18 15:51
6	108050	silicon adj nitride or (sin or "si.sub.3 n.sub.4")	USPAT; US-PGPUB; JPO	2002/06/18 15:49
7	171624	silicon adj (oxide or dioxide) or ("sio.sub.2")	USPAT; US-PGPUB; JPO	2002/06/18 15:50
8	136479	polish\$3 or cmp	USPAT; US-PGPUB; JPO	2002/06/18 15:51
9	38798	(silicon adj nitride or (sin or "si.sub.3 n.sub.4")) same (silicon adj (oxide or dioxide) or ("sio.sub.2"))	USPAT; US-PGPUB; JPO	2002/06/18 15:51
10	68497	(open\$3 or hole\$1) with (spacer\$1 or sidewall\$1)	USPAT; US-PGPUB; JPO	2002/06/18 15:55
11	2189	gate\$1 and implant\$3 and ((open\$3 or hole\$1) with (spacer\$1 or sidewall\$1))	USPAT; US-PGPUB; JPO	2002/06/18 15:55
12	1147	((silicon adj nitride or (sin or "si.sub.3 n.sub.4")) same (silicon adj (oxide or dioxide) or ("sio.sub.2"))) and (gate\$1 and implant\$3 and ((open\$3 or hole\$1) with (spacer\$1 or sidewall\$1)))	USPAT; US-PGPUB; JPO	2002/06/18 15:55
13	550	(polish\$3 or cmp) and (((silicon adj nitride or (sin or "si.sub.3 n.sub.4")) same (silicon adj (oxide or dioxide) or ("sio.sub.2"))) and (gate\$1 and implant\$3 and ((open\$3 or hole\$1) with (spacer\$1 or sidewall\$1))))	USPAT; US-PGPUB; JPO	2002/06/18 15:57
14	87640	photolithograph\$5 or lithograph\$5	USPAT; US-PGPUB; JPO	2002/06/18 15:57
15	403	((polish\$3 or cmp) and (((silicon adj nitride or (sin or "si.sub.3 n.sub.4")) same (silicon adj (oxide or dioxide) or ("sio.sub.2"))) and (gate\$1 and implant\$3 and ((open\$3 or hole\$1) with (spacer\$1 or sidewall\$1)))))) and (photolithograph\$5 or lithograph\$5)	USPAT; US-PGPUB; JPO	2002/06/18 15:58